

L Number	Hits	Search Text	DB	Time stamp
1	359474	etch\$3	USPAT; US-PGPUB; JPO	2004/09/21 15:49
2	144372	lithograph\$7 or photolithograph\$7	USPAT; US-PGPUB; JPO	2004/09/21 15:49
3	392327	mask\$3	USPAT; US-PGPUB; JPO	2004/09/21 15:50
4	19124	minimum same resolution\$1	USPAT; US-PGPUB; JPO	2004/09/21 15:51
5	1131220	pattern\$3	USPAT; US-PGPUB; JPO	2004/09/21 15:51
6	260912	spacer\$1	USPAT; US-PGPUB; JPO	2004/09/21 15:51
7	7251	hard adj2 mask\$3	USPAT; US-PGPUB; JPO	2004/09/21 15:52
8	307537	anti-reflect\$4 or antireflect\$4 or arc	USPAT; US-PGPUB; JPO	2004/09/21 15:52
9	699	(hard adj2 mask\$3) same (anti-reflect\$4 or antireflect\$4 or arc)	USPAT; US-PGPUB; JPO	2004/09/21 15:53
10	1664	(lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)	USPAT; US-PGPUB; JPO	2004/09/21 15:53
11	125640	etch\$3 same mask\$3	USPAT; US-PGPUB; JPO	2004/09/21 15:53
12	21194	etch\$3 same spacer\$1	USPAT; US-PGPUB; JPO	2004/09/21 15:53
13	371	((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1)	USPAT; US-PGPUB; JPO	2004/09/21 15:54
14	39	(anti-reflect\$4 or antireflect\$4 or arc) and (((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1))	USPAT; US-PGPUB; JPO	2004/09/21 15:54
15	9	((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1)) and ((hard adj2 mask\$3) same (anti-reflect\$4 or antireflect\$4 or arc))	USPAT; US-PGPUB; JPO	2004/09/21 15:54
16	30	((anti-reflect\$4 or antireflect\$4 or arc) and (((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1))) not (((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1)) and ((hard adj2 mask\$3) same (anti-reflect\$4 or antireflect\$4 or arc)))	USPAT; US-PGPUB; JPO	2004/09/21 15:54
17	332	((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1)) not ((anti-reflect\$4 or antireflect\$4 or arc) and (((lithograph\$7 or photolithograph\$7) same (minimum same resolution\$1)) and (etch\$3 same mask\$3) and (etch\$3 same spacer\$1)))	USPAT; US-PGPUB; JPO	2004/09/21 15:55